

REMARKS/ARGUMENTS

Prior to the first Office Action in the above-identified patent application, claim 1 is canceled without prejudice, waiver, or disclaimer to the subject matter contained therein, and claims 13-22 are added. A minor typographical error is also corrected in the amendment to the specification. No new matter has been added. Claims 13-22 remain in the application. Entrance of these amendments, and examination of the application, as amended, are respectfully requested.

In view of the foregoing, it is respectfully submitted that the application is in condition for allowance. Reexamination and reconsideration of the application, as amended, are requested.

If for any reason the Examiner finds the application other than in condition for allowance, the Examiner is requested to call the undersigned attorney at the Los Angeles, California telephone number (213) 337-6742 to discuss the steps necessary for placing the application in condition for allowance.

If there are any fees due in connection with the filing of this response, please charge the fees to our Deposit Account No. 50-1314.

Respectfully submitted,

HOGAN & HARTSON L.L.P.

Date: July 14, 2003

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Amendments to the Specification:

Please amend the paragraph beginning at page 7 line 23, as follows:

Subsequently, liquidized SiO_2 , for example, a material obtained by uniformly mixing the fluorescent substance with a tradename OCD (manufactured by Tokyo Ohka Kogyo Co., Ltd.) is uniformly applied with a spinner or the like, and a mask layer 14 with a film thickness of 50 nm or more, ~~20 nm~~ 20 μm or less is formed (FIG. 10B). A material of this mask layer will be described later.